

APPROVED	Ö.G. F	IG.
Ya	CLASS	SUBCLASS
DRAFTSHAH		

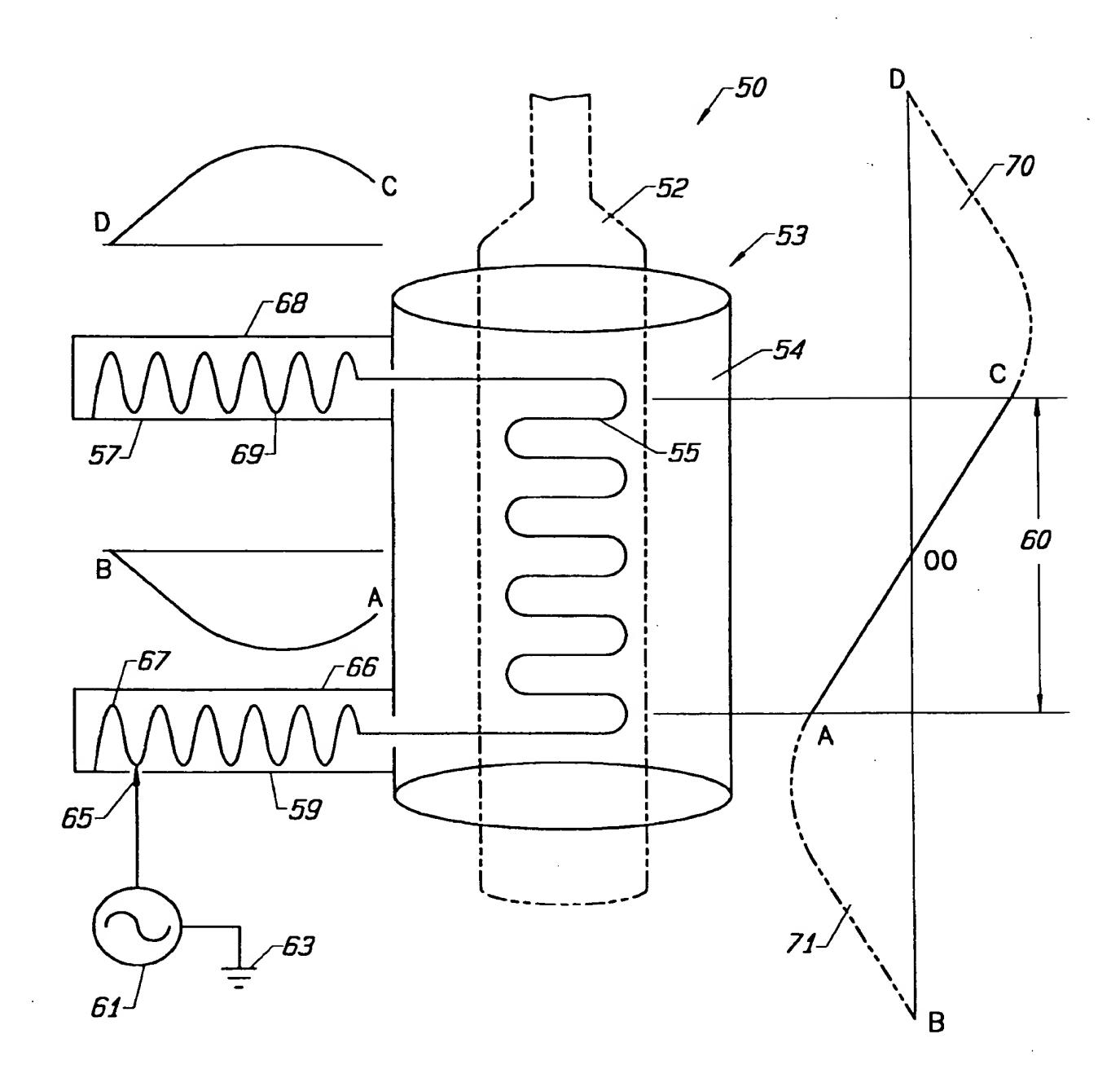
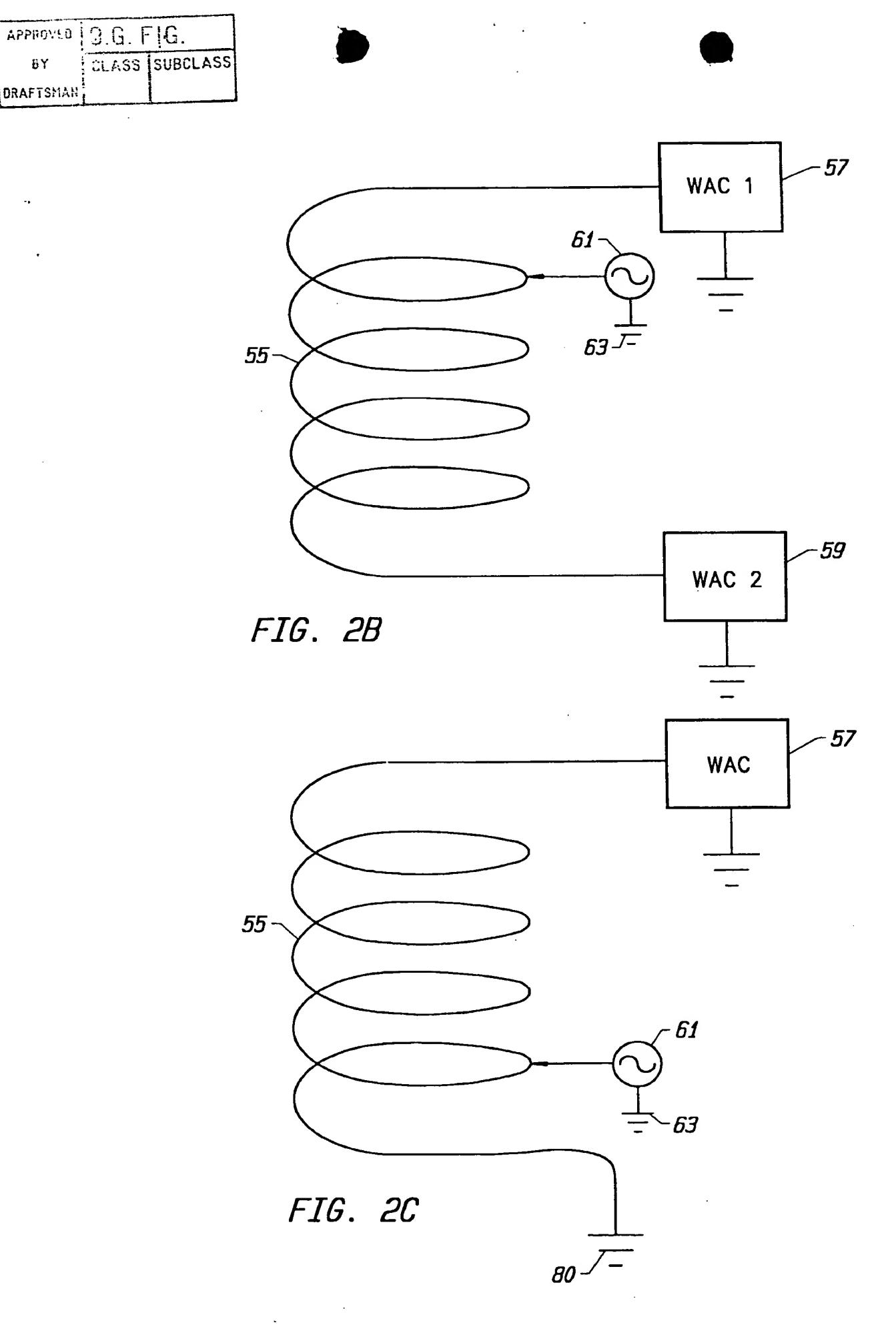


FIG. 2A



BY

DRAFTSMAN

APPROVED	0.G. F	iG.
BY	CLASS	SUBCLASS
DRAFTSHAN		

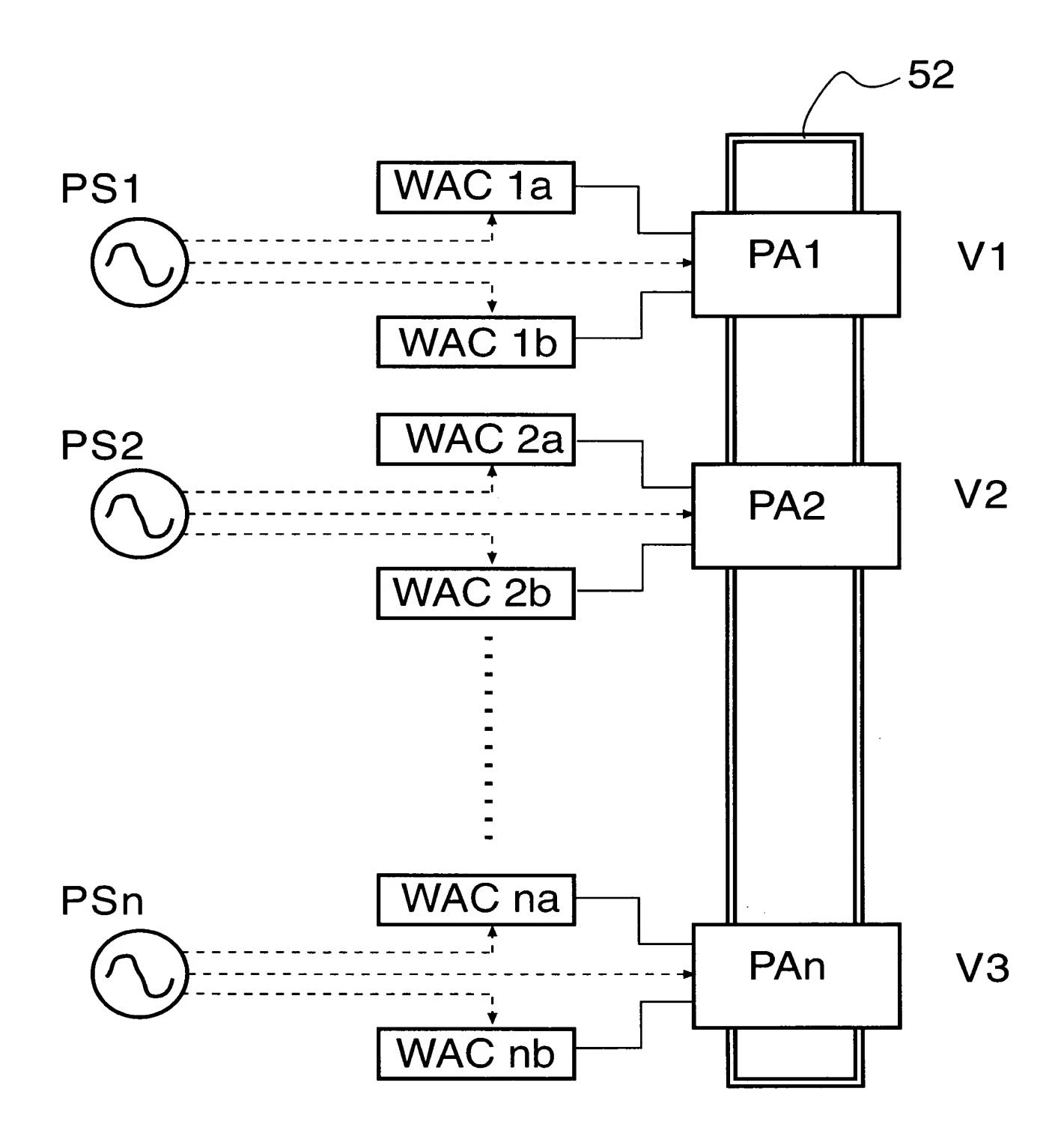
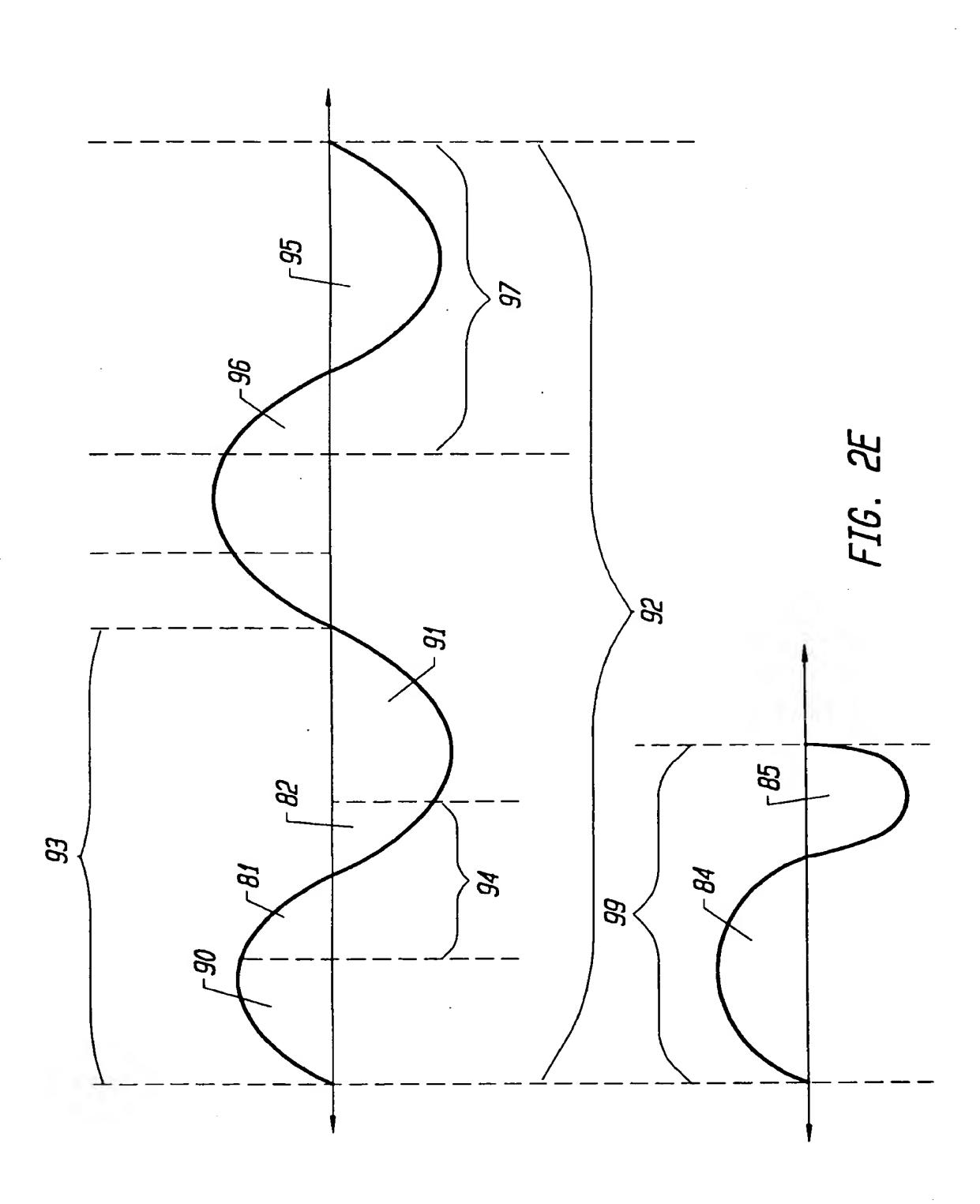


Fig. 2D

APPROVED		
βY	QLASS	SUBCLASS
DRAFTSMAH	1	



APPROVES	O.G. FIG.		
84	CLASS	SUBCLASS	
DRAFTSMAR			

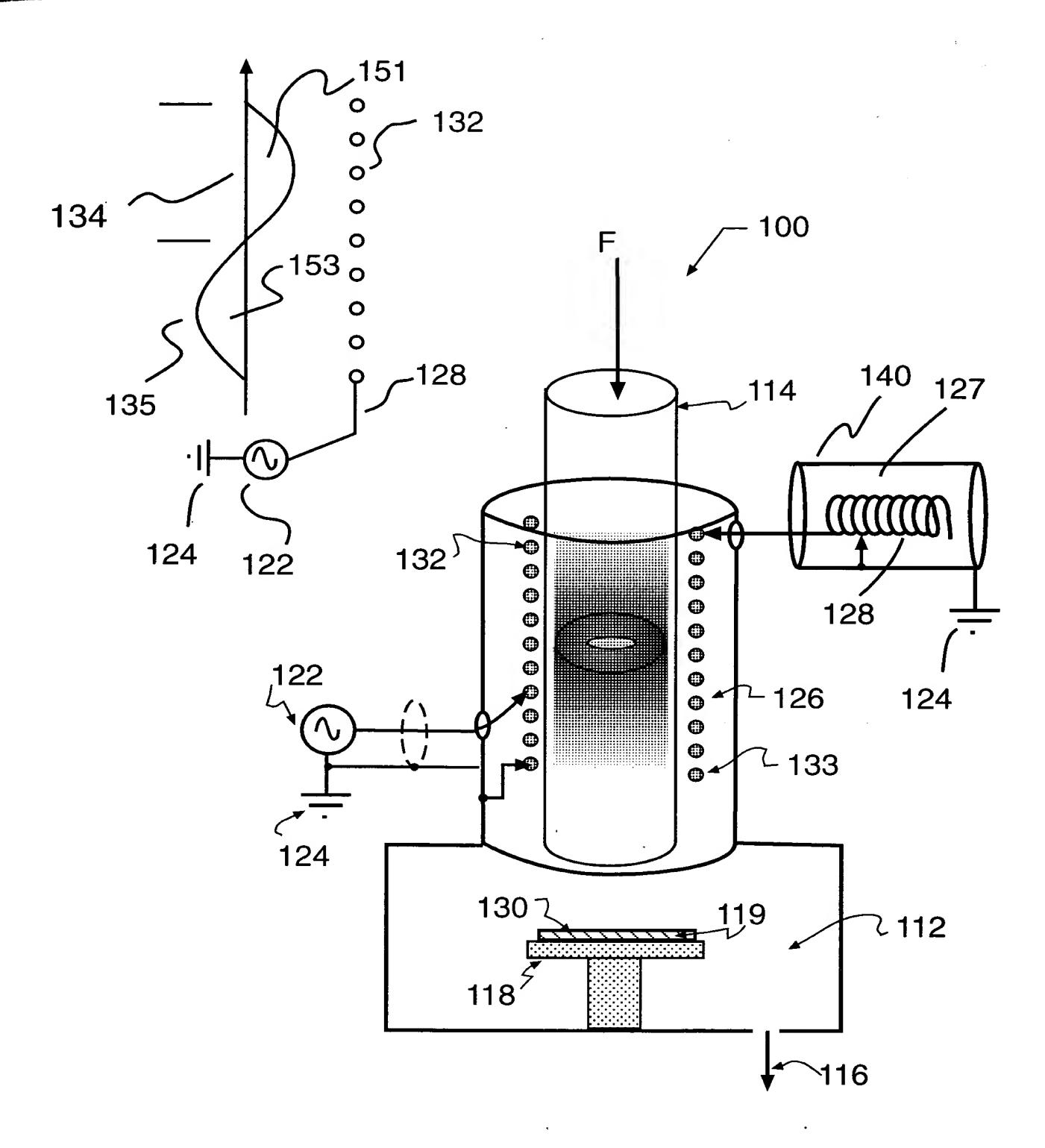
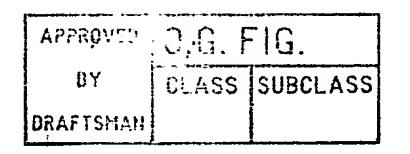


Fig. 3



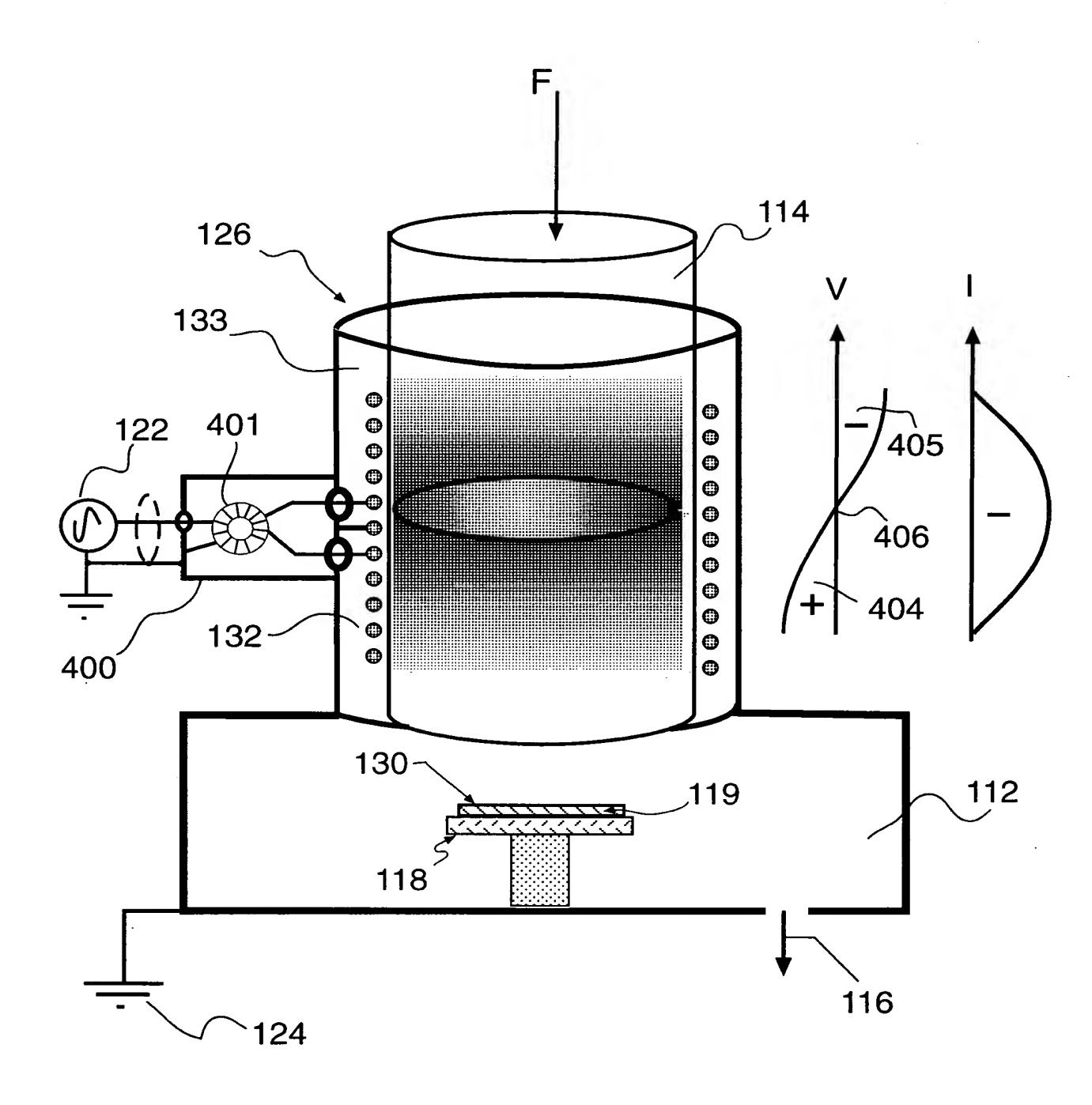


Fig. 4

APPROVED	0.G. F	iG.
94	CLASS	SUBCLASS
DRAFTSMAH		

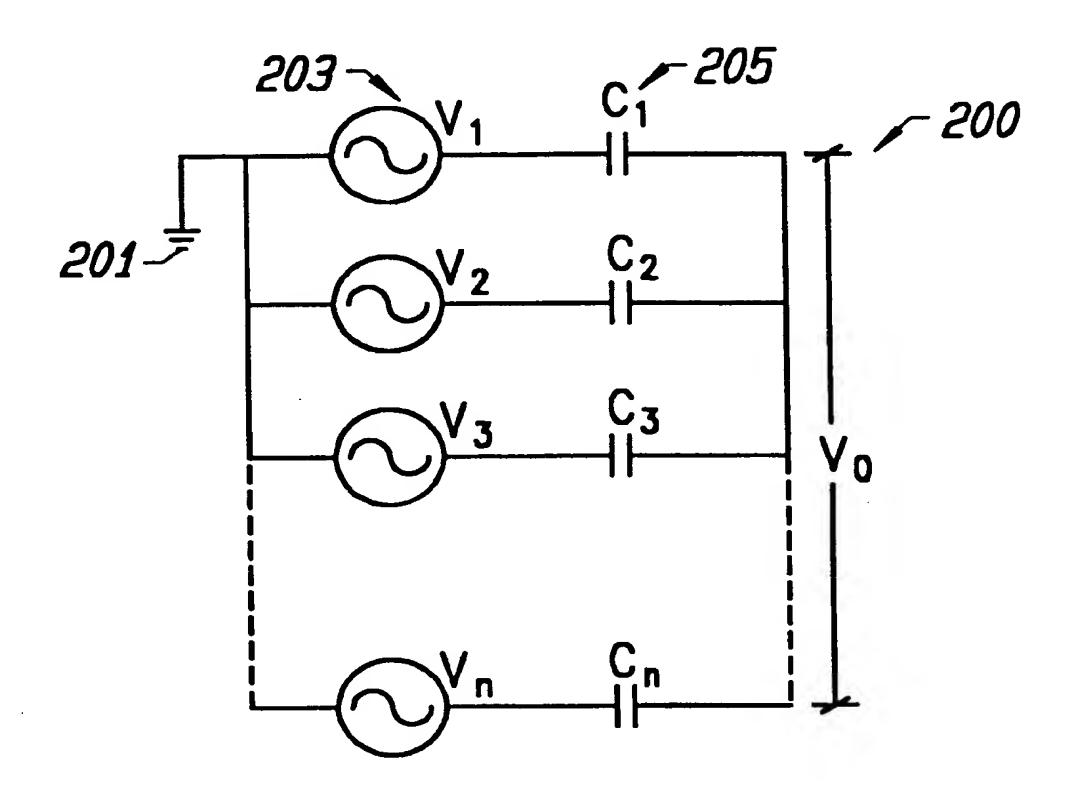
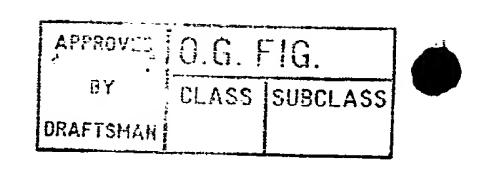
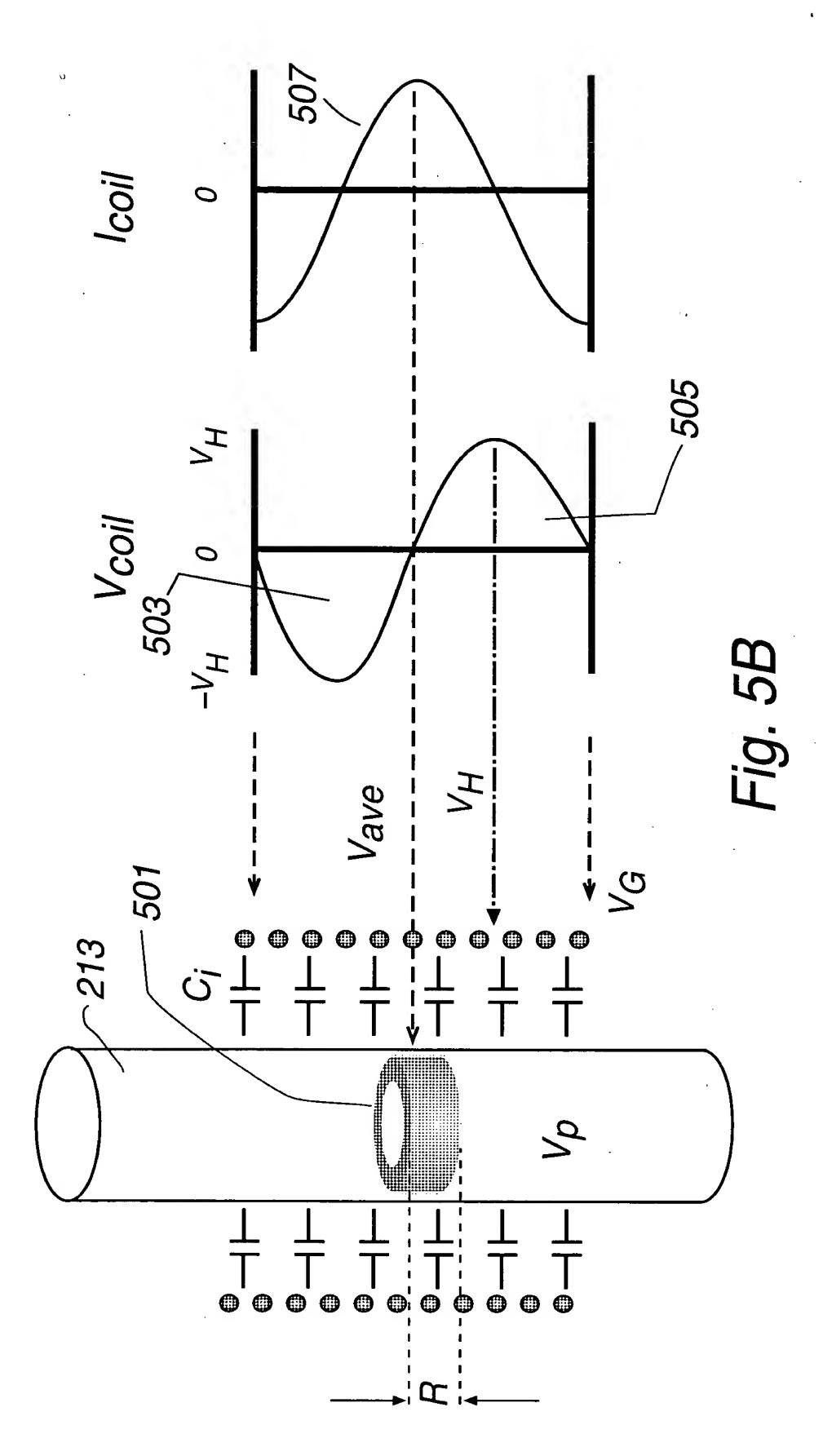


FIG. 5A





APPROVES	Ö.G. 1	FIG.
37	CLASS	SUBCLASS
DRAFTSMAN		

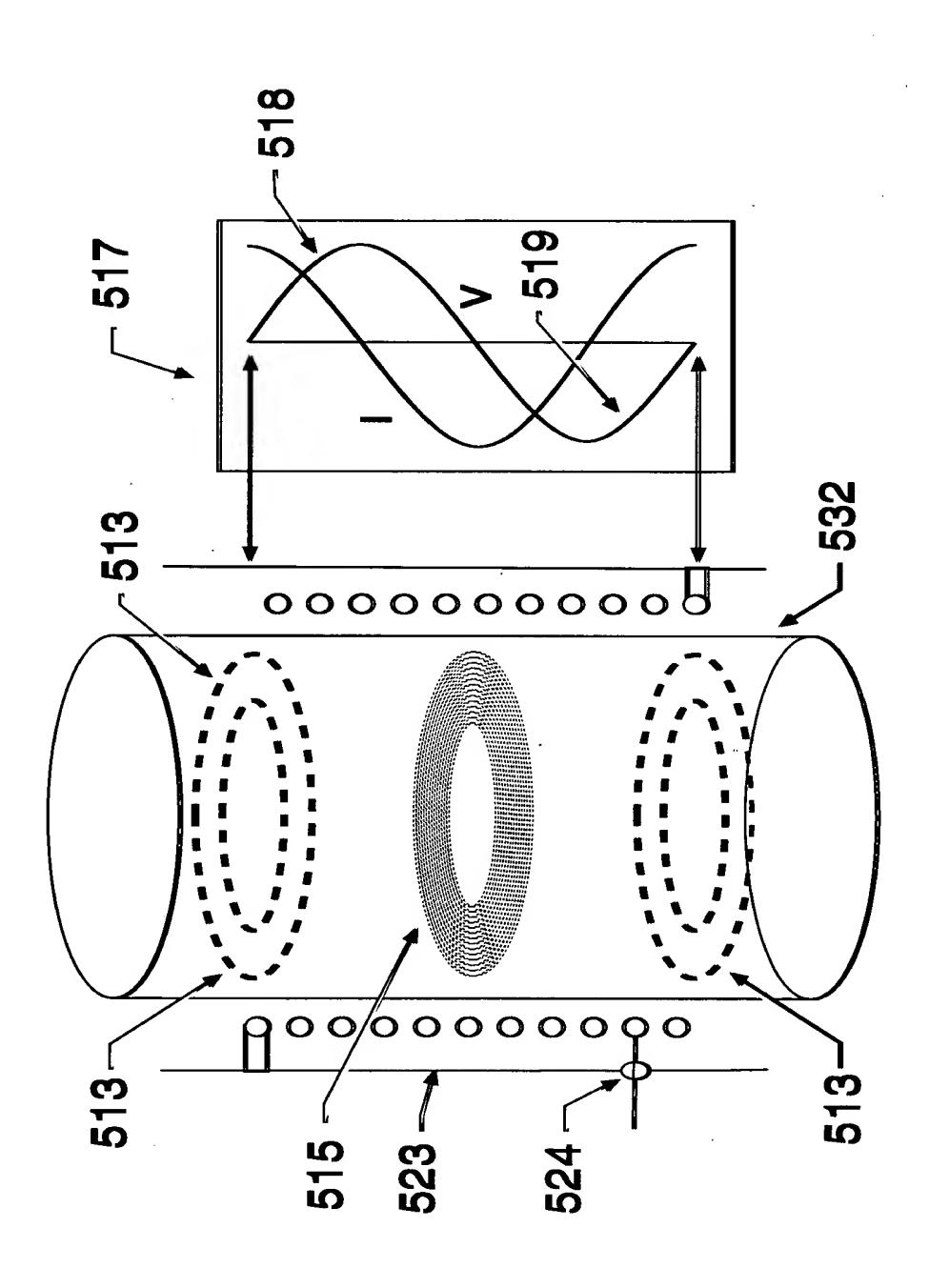


Fig. 50

APPROVE	O:G: FIG.	
ΒY	CLASS	SUBCLASS
DRAFTSHAH		

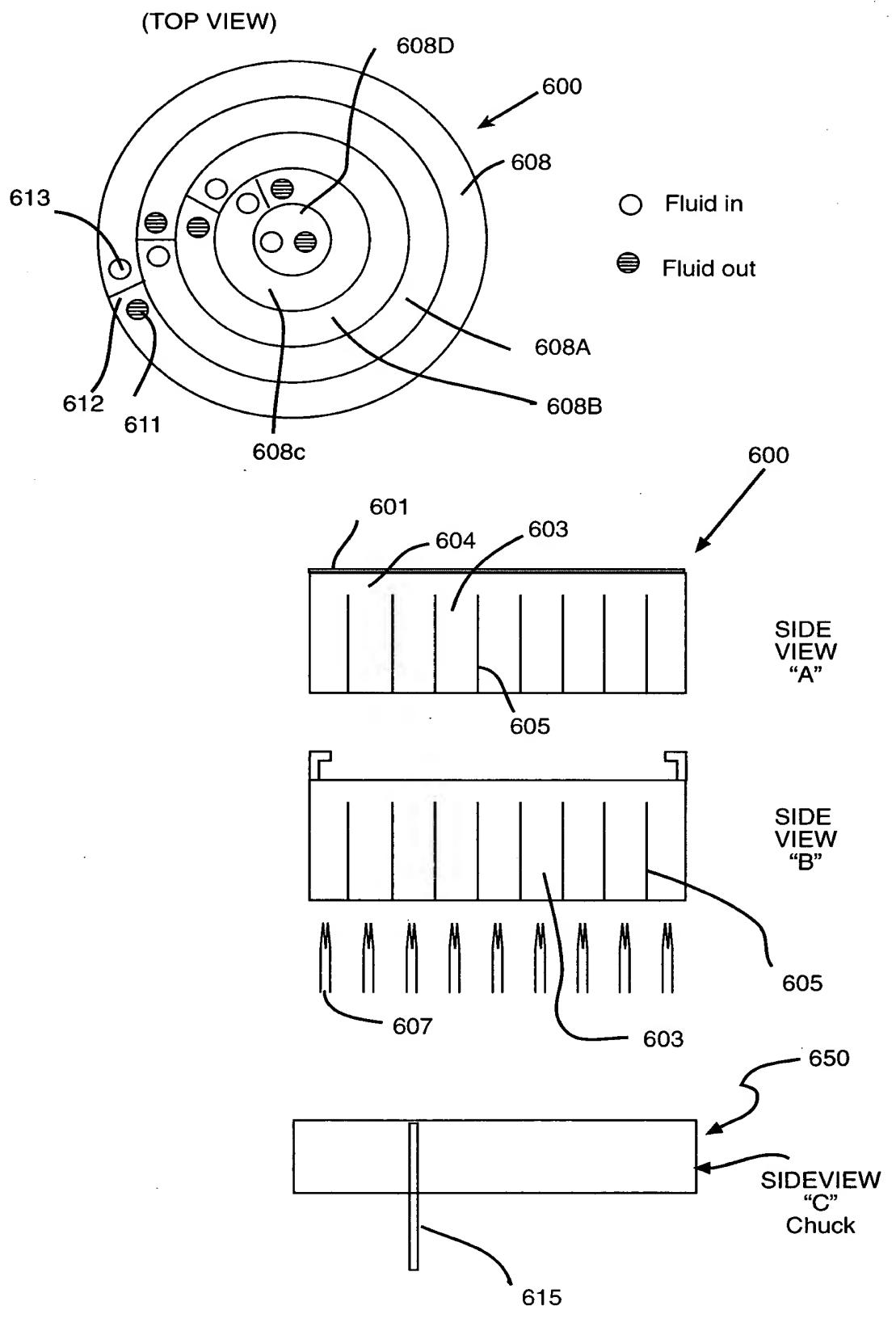
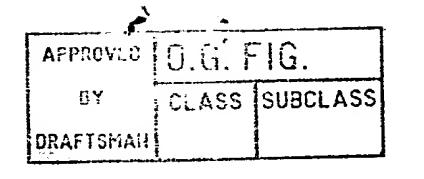


FIG. 6



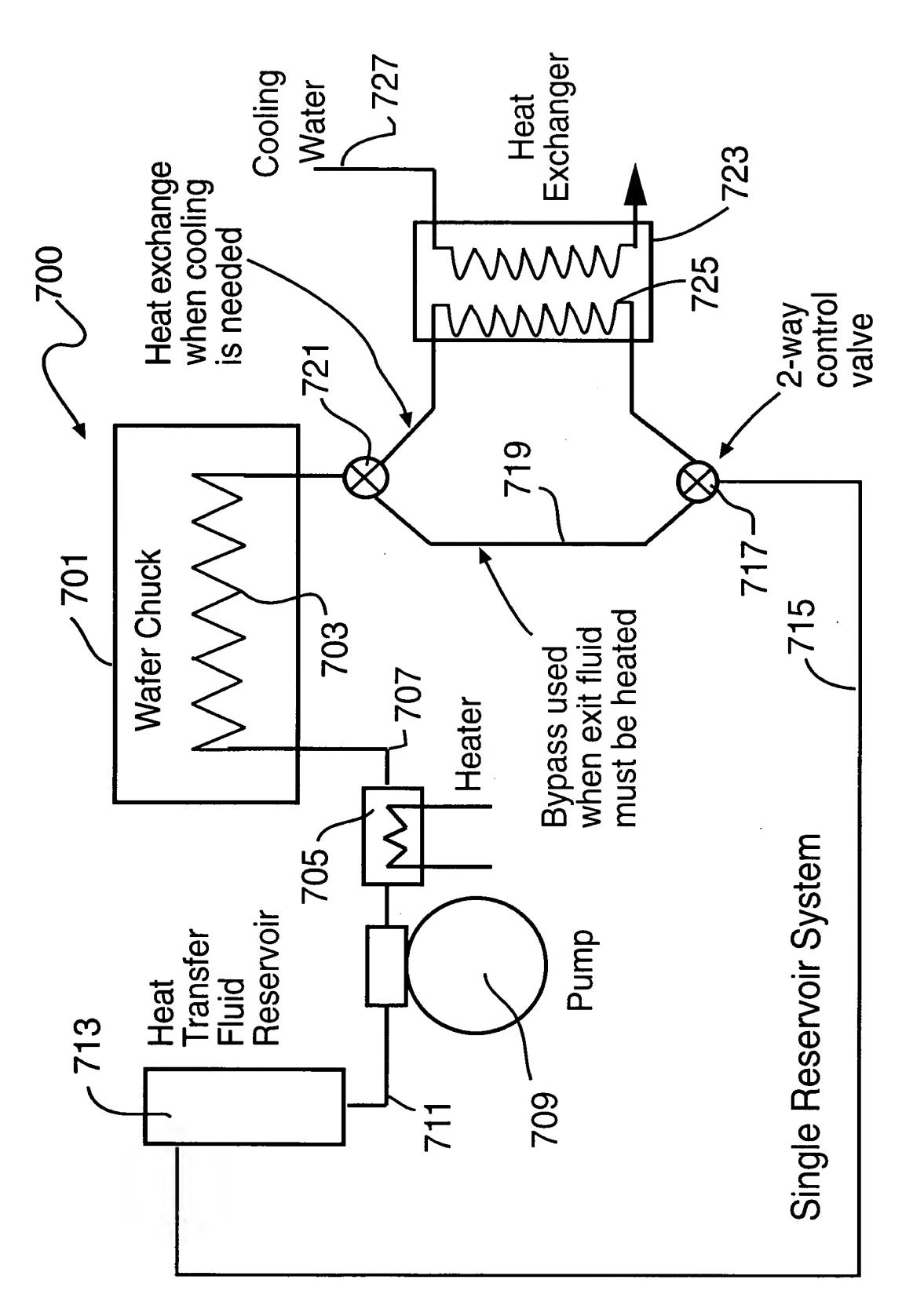


Fig. 7

APPROVET	C.G. F	IG.
ey	CLASS	SUBCLASS
DRAFTSMAN		

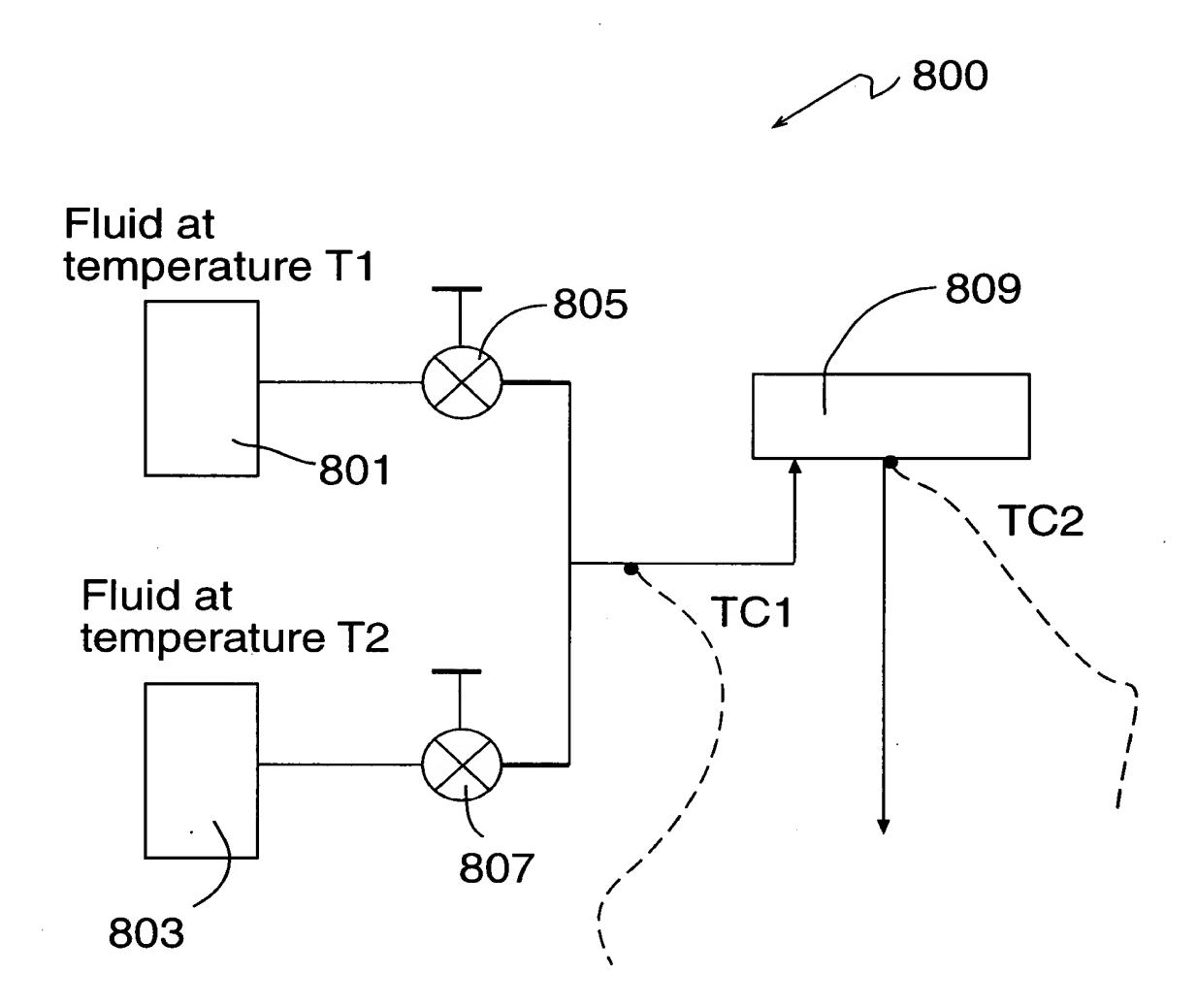


Fig. 8

APPROVEG	G.G. FIG.	
84	CLASS	SUBCLASS
DRAFTSMAH	one s + 4 Palls differen	

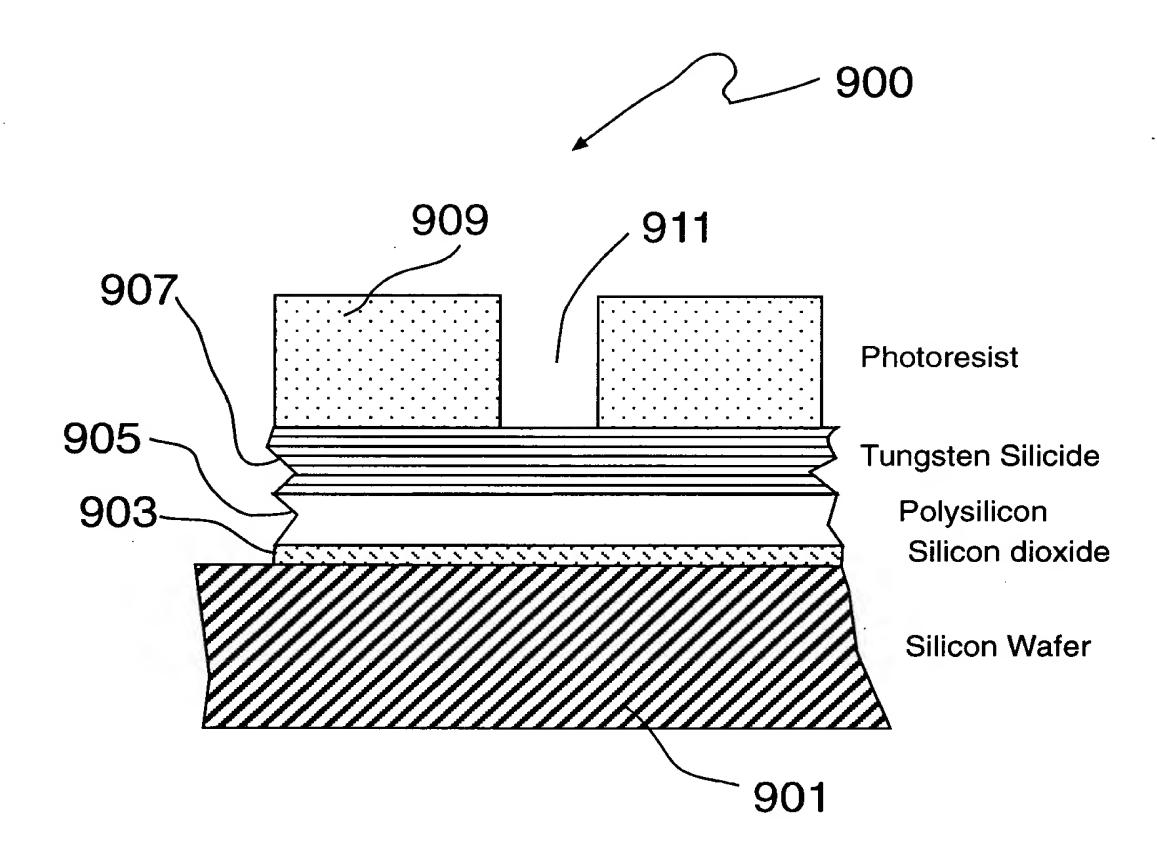
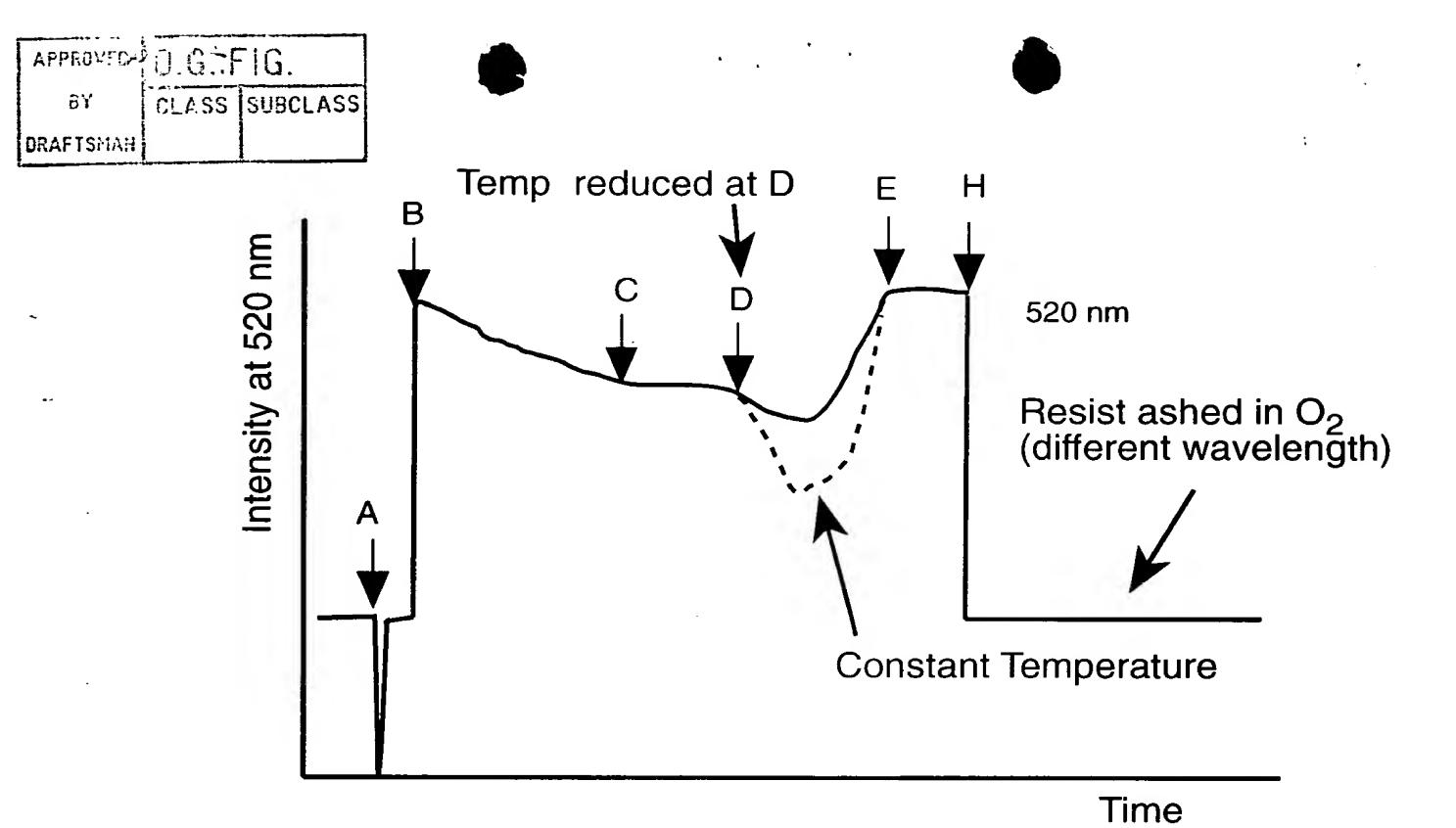
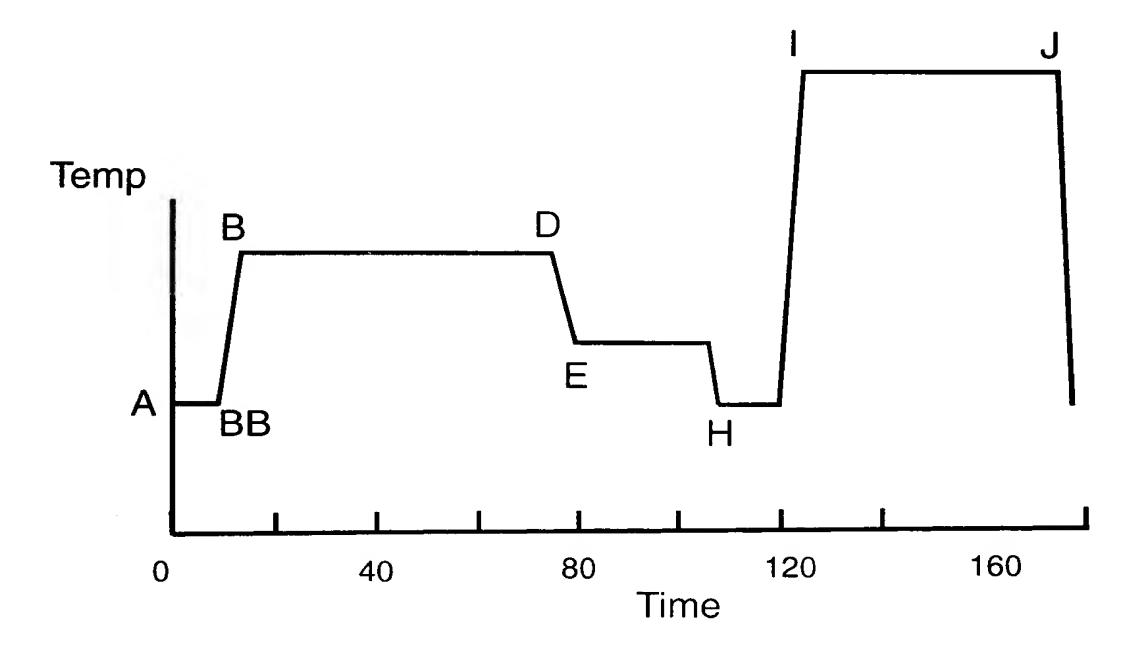


Fig. 9





- A. SF₆ native oxide "breakthrough"
- B. Cl₂ plasma is ignited
- C. WSi_x begins to clear (endpoint)
- D. Polysilicon is exposed
- E. Polysilicon cleared to oxide
- H. Plasma extinguished and O2 feed gas flow is started
- 1. O₂ plasma is started
- J O₂ plasma is extinguished.

Fig. 10